

APPLICATION DATA SHEET

APPLICATION INFORMATION

Application Number::

Filing Date::

Application type:: Regular

Subject Matter:: Utility

Title:: Plasma Processing System

Attorney Docket No.: 101248.55500US

Request for Early Publication?: No

Request for Non-Publication?: No

Total Drawings:: 6

Small Entity?: No

Petition included?: No

APPLICANT INFORMATION

Applicant one Authority Type:: Inventor

Primary Citizenship:: Japanese

Country:: Japan

Status:: Full Capacity

Given name:: Nobuo

Family name:: ISHII

Country of Residence:: JAPAN

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City:: Amagasaki-shi

State or Province of Country:: Hyogo

Postal or Zip Code::

CORRESPONDENCE INFORMATION

Correspondence customer number:: 23911

REPRESENTATIVE INFORMATION

Representative customer number:: 23911

DOMESTIC PRIORITY INFORMATION

Application::	Continuity Type::	Parent Application::	Parent Filing Date::
This is the	National Phase	PCT/JP03/04447	04/08/2003

FOREIGN PRIORITY INFORMATION

Country::	Application No.::	Filing Date::	Priority Claimed::
JP	2002-106776	04/09/2002	Yes

ASSIGNEE INFORMATION

Assignee Name:: Tokyo Electron Limited
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City:: Minato-ku
State or Province:: Tokyo
Country:: Japan